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# Electrical and Thermal Properties of Ti<sub>3</sub>AlC<sub>2</sub> at High Temperature

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#### Abstract

In this paper, we report on the electrical and thermal properties of predominantly single-phase  $Ti_3AlC_2$  ceramics (96.7 wt%) as a function of temperature. The results show that  $Ti_3AlC_2$  is a good electrical and thermal conductor at high temperature. From 300 to 1173 K, the electrical resistivity of  $Ti_3AlC_2$  increases linearly from  $3.4 \times 10^{-5}$  to  $1.1 \times 10^{-4} \Omega \cdot m$ , which indicates that  $Ti_3AlC_2$  ceramic is a metallic conductor. In the 473 to 1473 K temperature range, the coefficient of thermal expansion of  $Ti_3AlC_2$  yields an average value of  $9.3 \times 10^{-6} \text{ K}^{-1}$ , which is comparable with the coefficients of  $Ti_2AlC$  and  $Ti_3SiC_2$ . The thermal conductivity increases from 22.6 to 26.4 W·m<sup>-1</sup>·K<sup>-1</sup> with rising temperature from 473 to 1473 K. It is found that the electronic contribution to the thermal conductivity is the dominant mechanism. The molar heat capacity of  $Ti_3AlC_2$  is 138.6 J·mol<sup>-1</sup>·K<sup>-1</sup> at 473 K and extrapolates to 168.5 J·mol<sup>-1</sup>·K<sup>-1</sup> at 1473 K.

Keywords: Ceramics, thermal conductivity, thermal expansion, electrical properties

## I. Introduction

 $Ti_3AlC_2$  is an important member of  $M_{n+1}AX_n$  phase (n=1-3), where M = early transition metal, A = an A-group element (mostly IIIA and IVA), and X = C or N<sup>1-4</sup>. And it has been proven that Ti<sub>3</sub>AlC<sub>2</sub> combines the unique properties of both ceramics and metals. Similar to ceramics, Ti<sub>3</sub>AlC<sub>2</sub> is oxidation resistant <sup>5-8</sup>, high-temperature stable up to 1360 °C 9,10 and lightweight with a measured low density of 4.21 g/cm<sup>311</sup>. Similar to metals, Ti<sub>3</sub>AlC<sub>2</sub> is elastically stiff with a Young's modulus of 297 GPa, damage- and thermal-shock-tolerant <sup>12</sup>, and it behaves quasi-plastically under compression at temperatures above 1000 °C<sup>2,13</sup>. Such salient properties make Ti<sub>3</sub>AlC<sub>2</sub> suitable for potential applications in high-temperature areas. The electrical properties <sup>13</sup> and the thermal properties of Ti<sub>3</sub>AlC<sub>2</sub><sup>14</sup> at low temperatures (<285 K) have been well studied. However, as far as we are aware, there are no reports about the electrical and thermal properties of Ti<sub>3</sub>AlC<sub>2</sub> at high temperature. In this paper, Ti<sub>3</sub>AlC<sub>2</sub> fabricated by means of self-propagating hightemperature synthesis (SHS) and its electrical resistance was investigated at 300-1173 K. The coefficient of thermal expansion, thermal conductivity and the heat capacity of  $Ti_3AlC_2$  were also reported for the 473 – 1473 K range.

# II. Experimental

Polycrystalline  $Ti_3AlC_2$  was fabricated by means of the SHS technique; the experimental details can be found elsewhere <sup>3</sup>. In brief, Ti, Al and C elemental powders were ad-

equately ball-milled in a nylon jar using WC balls. After mixing and drying, the powders were cold-compressed into a cylindrical compact of 55 mm diameter  $\times 25$  mm height with a compact density of 60 % of the theoretical density. The SHS experiments were performed in a stainlesssteel combustion chamber. The Ti-Al-C compact was ignited from one end by a tungsten heating element, and then the combustion wave quickly propagated. As soon as the combustion wave extinguished, a pressure of 200 MPa was applied for 20 s to obtain densified samples. To avoid oxidation, the resultant samples were then quickly transferred into sand and cooled down to room temperature. XRD quantitative results <sup>15</sup> show that there is a predominant percentage of Ti3AlC2 (96.7 wt%) and very low impurity of TiC (3.3 wt%). XRD results also demonstrate that there is no preferential orientation. The relative density is calculated to be 97 % according to the Archimedes' principle. SEM results show the grain size of Ti<sub>3</sub>AlC<sub>2</sub> is of the average order of  $10 \,\mu m$ .

The electrical resistance and its temperature dependence were measured using a 2 mm  $\times$  2 mm  $\times$  15 mm sample with a four-point probe method at 300–1173 K using selfdesigned equipment. The coefficient of thermal expansion (CTE) was measured with a Unitherm<sup>TM</sup> 1252 ultrahigh temperature dilatometer (Anter Corp., Pittsburgh, USA) in the temperature range of 473–1473 K in an argon atmosphere. The thermal conductivity and thermal diffusivity were measured using a disk sample measuring Ø12.7 mm  $\times$  3.14 mm with a Flashline TM 5000 thermal properties analyzer (Anter Corp., Pittsburgh, USA).

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The heat capacity,  $C_p$  (J·mol<sup>-1</sup>·K<sup>-1</sup>), was calculated according to the following equation:

$$C_{p} = \frac{k}{\alpha \rho}$$
(1)

where *k* is the thermal conductivity (W·m<sup>-1</sup>·K<sup>-1</sup>),  $\alpha$  thermal diffusivity (cm<sup>2</sup>·s<sup>-1</sup>) and  $\rho$  the density (g·cm<sup>-3</sup>).

# III. Results and Discussion

#### (1) Electrical properties

Fig. 1 shows the electrical resistivity and the conductivity as a function of temperature from 300 to 1173 K. The relationship between electrical conductivity and electrical resistivity is

$$\rho = \frac{1}{\sigma} \tag{2}$$

where  $\rho$  is the electrical resistivity ( $\Omega \cdot m$ ),  $\sigma$  is the electrical conductivity ( $\Omega^{-1} \cdot m^{-1}$ ). At room temperature, the electrical conductivity of Ti<sub>3</sub>AlC<sub>2</sub> is  $2.9 \times 10^{6} \Omega^{-1} \cdot m^{-1}$ , which is close to that of Ti<sub>2</sub>AlC  $(2.8 \times 10^{6} \Omega^{-1} \cdot m^{-1})^{16}$ , but less than that of Ti<sub>3</sub>SiC<sub>2</sub>  $(4.5 \times 10^{6} \Omega^{-1} \cdot m^{-1})$ <sup>17</sup>. At a higher temperature of 750 K, our calculated data yield an electrical conductivity of  $1.29 \times 10^{6} \Omega^{-1} \cdot m^{-1}$ , in good agreement with the previous result of  $1.23 \times 10^6 \ \Omega^{-1} \cdot m^{-1}$ . This testifies to the reliability and accuracy of our measurement. With increasing temperature from 300 to 1173 K, the electrical resistivity of Ti<sub>3</sub>AlC<sub>2</sub> increases linearly from  $3.4 \times 10^{-5}$ to  $1.1 \times 10^{-4} \ \Omega$ ·m. Based on the Bloch-Grüneisen law, it is known that the electrical resistivity of a metal shows a direct proportionality with the temperature greater than 0.5 Debye temperature. The reported Debye temperature of Ti<sub>3</sub>AlC<sub>2</sub> is 764 K<sup>14</sup>. Therefore, from the viewpoint of electrical conduction, Ti<sub>3</sub>AlC<sub>2</sub> exhibits the same conducting mechanism as a metal and therefore is a metallic conductor. A least square fit of data in Fig. 1 yields the expression:

$$\rho = \rho_0 [1 - \beta \Delta T] = 11.49 [1 - 0.0082 (1173 - T)]$$
(3)

where  $\varrho_0$  is the electrical resistivity at 1173 K ( $\mu\Omega$ ·m),  $\beta$  the temperature coefficient of resistivity and *T* the absolute temperature (K).



Fig. 1 Electrical resistivity and conductivity of  $Ti_3AlC_2$  as a function of temperature.

#### (2) Thermal properties

Fig. 2(a) shows the thermal expansion of  $Ti_3AlC_2$  in the temperature range of 473-1473 K upon heating. It can be seen that the unit linear expansion increases with rising temperature. The CTE increases slightly at the initial and final stages, respectively, whereas it remains steady in the middle temperature range. The linear fit of the data yields a mean CTE of  $9.3 \times 10^{-6}$  K<sup>-1</sup>, which is greater than the CTEs of Ti<sub>2</sub>AlC (8.7×10<sup>-6</sup> K<sup>-1</sup>)<sup>16</sup> and Ti<sub>3</sub>SiC<sub>2</sub>  $(9.2 \times 10^{-6} \text{ K}^{-1})^{18}$ . This value is in good agreement with the reported value of  $(9.0 \pm 0.2) \times 10^{-6} \text{ K}^{-1}$  for Ti<sub>3</sub>Al<sub>1.1</sub>C<sub>1.8</sub> over the 298-1473 K temperature range. The temperature dependence of the thermal diffusivity was plotted in Fig. 2(b). It is found that the thermal diffusivity basically remains the same with the increase in temperature. As shown in Fig. 2(c), the thermal conductivity of  $Ti_3AlC_2$ increases from 22.6 to 26.4 W·m<sup>-1</sup>·K<sup>-1</sup> with rising temperature from 473 to 1473 K. In general, the total thermal conductivity,  $k_{\text{total}}$ , is associated with both the electronic and phonon contributions, i.e.,

$$k_{total} = k_e + k_{ph} \tag{4}$$

where  $k_e$  and  $k_{ph}$  are the electronic and phonon contributions to the total conductivity, respectively.  $k_e$  can be calculated according to the Wiedemann-Frans law:

$$k_e = \frac{L_0 T}{\rho}$$
(5)

where  $\rho$  and T have the same meanings as defined previously, and  $L_0$  Lorenz number (2.45×10<sup>-8</sup> W· $\Omega$ ·K<sup>-2</sup>). To date, this expression has been found to be valid for many MAX phases <sup>1</sup>. At 1300 K, the calculated  $k_e$  of Ti<sub>3</sub>AlC<sub>2</sub> is 23.7 W·m<sup>-1</sup>·K<sup>-1</sup>, which is very close to the total thermal conductivity,  $k_{total}$ , 26.4 W·m<sup>-1</sup>·K<sup>-1</sup>. Based on this observation, it can be concluded that for Ti<sub>3</sub>AlC<sub>2</sub>, the electron contributes greater to the thermal conductivity at high temperature. For comparison, the thermal conductivities of selected MAX phase materials are listed here <sup>16</sup>, see Table 1. The highest  $k_{total}$  at 1300 K belongs to Ti<sub>2</sub>AlC. Moreover, from the table, we can see that the electron plays a major role in the thermal conduction for the five MAXphase compounds at high temperature.

Table 1: The thermal conductivities of selected MAX-phase materials.

Compound	$k_{\text{tot}}$ (W·m <sup>-1</sup> ·K <sup>-1</sup> )	$k_{e}$ (W·m <sup>-1</sup> ·K <sup>-1</sup> )	$k_{\rm ph}$ (W·m <sup>-1</sup> ·K <sup>-1</sup> )
Ti <sub>2</sub> AlC	36	19.7 (55 %)	15 (38 %)
Nb <sub>2</sub> SnC	30	25 (82 %)	5 (18%)
Ti <sub>3</sub> AlC <sub>2</sub>	25	23.7 (95 %)	1.3 (5 %)
Ti <sub>3</sub> SiC <sub>2</sub>	33	32 (97 %)	1 (3 %)
Ti <sub>4</sub> AlN <sub>2.9</sub>	20	10 (50 %)	10 (50 %)



Fig. 2 Temperature dependence of (a) thermal expansion, (b) thermal diffusivity, (c) thermal conductivity and (d) molar thermal capacity of  $Ti_3AIC_2$ .

According to Eq. (1), the molar heat capacity of the sample was calculated at 473 – 1473 K. Fig. 2 (d) plots the temperature dependence of  $C_p$ . Like most MAX phases studied to date, it can be seen that the  $C_p$  of Ti<sub>3</sub>AlC<sub>2</sub> increased with rising temperature. However, recent work on Ti<sub>2</sub>AlC and Ti<sub>2</sub>InC showed a decrease of  $C_p$  with increasing temperatures owing to the loss of A-group element, i.e. Al and In <sup>16, 19</sup>, respectively. At 473 and 1470 K, the molar heat capacity of Ti<sub>3</sub>AlC<sub>2</sub> is 138.6 and 168.5 J·mol<sup>-1</sup>·K<sup>-1</sup>, respectively, which is higher than those of Ti<sub>2</sub>AlC (91.64 and 111.27 J·mol<sup>-1</sup>·K<sup>-1</sup>) <sup>16</sup>.

## **IV.** Conclusion

Ti<sub>3</sub>AlC<sub>2</sub> is demonstrated to be a good electrical and thermal conductor. In the temperature range of 300 - 1173 K, the electrical conductivity decreases from  $2.9 \times 10^6$  to  $9.1 \times 10^5 \Omega^{-1} m^{-1}$ . In the 473 to 1473 K temperature range, the coefficient of thermal expansion yields an average value of  $9.3 \times 10^{-6}$  K<sup>-1</sup>. The thermal conductivity increases from 22.6 to 26.4 W·m<sup>-1</sup>·K<sup>-1</sup> and the molar heat capacity increases from 138.6 to 168.5 J·mol<sup>-1</sup>·K<sup>-1</sup> in the 473 – 1473 K range.

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## References

- <sup>1</sup> Barsoum, M.W.: The M<sub>N+1</sub>AX<sub>N</sub> phases: A new class of solids; thermodynamically stable nanolaminates, *Prog. Solid State Ch.*, 28, 201–281, (2000).
- <sup>2</sup> Tzenov, N.V., Barsoum, M.W.: Synthesis and characterization of Ti<sub>3</sub>AlC<sub>2</sub>, *J. Am. Ceram. Soc.*, 83, 825-832, (2000).
- <sup>3</sup> Lin, Z.J., Zhuo, M.J., Zhou, Y.C., Li, M.S., Wang, J.Y.: Microstructural characterization of layered ternary Ti<sub>2</sub>AlC, *Acta Mater.*, 54, 1009–1015, (2006).
- <sup>4</sup> Yeh, C.L., Kuo, C.W., Chu, Y.C.: Formation of Ti<sub>3</sub>AlC<sub>2</sub>/Al<sub>2</sub>O<sub>3</sub> and Ti<sub>2</sub>AlC/Al<sub>2</sub>O<sub>3</sub> composites by combustion synthesis in Ti-A-C-TiO<sub>2</sub> systems, *J. Alloy Compd.*, **494**, 132–136, (2010).
- <sup>5</sup> Wang, X.H., Zhou, Y.C.: Oxidation behavior of Ti<sub>3</sub>AlC<sub>2</sub> at 1000-1400 °C in air, *Corros. Sci.*, **45**, 891-907, (2003).

- <sup>6</sup> Qian, X.K., Li, Y.B., Sun, Y., He, X.D., Zhu, C.C.: Cyclic oxidation behavior of TiC/Ti<sub>3</sub>AlC<sub>2</sub> composites at 550-950 °C in air, *J. Alloy Compd.*, **491**, 386-390, (2010).
- <sup>7</sup> Lin, Z.J., Zhuo, M.J., Zhou, Y.C., Li, M.S., Wang, J.Y.: Interfacial microstructure of Ti<sub>3</sub>AlC<sub>2</sub> and Al<sub>2</sub>O<sub>3</sub> oxide scale, *Scripta Mater.*, 54, 1815–1820, (2006).
- <sup>8</sup> Qian, X.K., He, X.D., Li, Y.B., Li, H., Xu, D.L.: Cyclic oxidation of Ti<sub>3</sub>AlC<sub>2</sub> at 1000-1300 °C in air, *Corros. Sci.*, **53**, 290-295, (2011).
- <sup>9</sup> Lopacinski, M., Puszynski, J., Lis, J.: Synthesis of ternary titanium aluminum carbides using self-propagating high-temperature synthesis technique, *J. Am. Ceram. Soc.*, 84, 3051-3053, (2001).
- <sup>10</sup> Zhu, C.C., Qian, X.K., He, X.D., Xian, H.Z.: Combustion synthesis and thermal stability of Ti<sub>3</sub>AlC<sub>2</sub>, *Rare Metal Mat. Eng.*, **38**, 86-89, (2009).
- <sup>11</sup> Wang, X.H., Zhou, Y.C.: Solid-liquid reaction synthesis of layered machinable Ti<sub>3</sub>AlC<sub>2</sub> ceramic, *J. Mater. Chem.*, **12**, 455-460, (2002).
- <sup>12</sup> Bao, Y.W., Wang, X.H., Zhang, H.B., Zhou, Y.C.: Thermal shock behavior of Ti<sub>3</sub>AlC<sub>2</sub> from between 200 °C and 1300 °C, *J. Eur. Ceram. Soc.*, **25**, 3367–3374, (2005).

- <sup>13</sup> Wang, X.H., Zhou, Y.C.: Microstructure and properties of Ti<sub>3</sub>AlC<sub>2</sub> prepared by the solid-liquid reaction synthesis and simultaneous *in-situ* hot pressing process, *Acta Mater.*, 50, 3141-3149, (2002).
- <sup>14</sup> Ho, J.C., Hamdeh, H.H., Barsoum, M.W., El-Raghy, T.: Lowtemperature heat capacities of Ti<sub>3</sub>Al<sub>1.1</sub>C<sub>1.8</sub>, Ti<sub>4</sub>AlN<sub>3</sub>, and Ti<sub>3</sub>SiC<sub>2</sub>, *J. Appl. Phys.*, **86**, 3609, (1999).
- <sup>15</sup> Wang, C.A., Zhou, A.G., Qi, L., Huang, Y.: Quantitative phase analysis in the ti-al-c ternary system by x-ray diffraction, *Powder Diffr.*, 20, 218–223, (2005).
- <sup>16</sup> Barsoum, M.W., Salama, I., El-Raghy, T., Golczewski, J., Porter, W.D., Wang, H., Seifert, H.J., Aldinger, F.: Thermal and electrical properties of Nb<sub>2</sub>AlC, (Ti, Nb)<sub>2</sub>AlC and Ti<sub>2</sub>AlC, *Metall. Mater. Trans. A.*, **33**, 2775–2779, (2002).
- <sup>17</sup> Barsoum, M.W., El-Raghy, T.: Synthesis and characterization of a remarkable ceramic: Ti<sub>3</sub>SiC<sub>2</sub>, *J. Am. Ceram. Soc.*, 79, 1953-1956, (1996).
- <sup>18</sup> Barsoum, M.W., El-Raghy, T., Rawn, C.J., Porter, W.D., Wang, H., Payzant, E.A., Hubbard, C.R.: Thermal properties of Ti<sub>3</sub>SiC<sub>2</sub>, *J. Phys. Chem. Solids*, 60, 429-439, (1999).
- <sup>19</sup> Barsoum, M.W., Golczewski, J., Seifert, H.J., Aldinger, F.: Fabrication and electrical and thermal properties of Ti<sub>2</sub>InC, Hf<sub>2</sub>InC and (Ti,Hf)<sub>2</sub>InC, *J. Alloy. Compd.*, **340**, 173–179, (2002).